Abstract Submitted to the International Conference on Strongly Correlated Electron Systems University of Michigan, Ann Arbor August 6-10, 2001

Hybridization gap in Kondo insulators CeRhAs and CeRhSb studied by ultrahigh-resolution photoemission spectroscopy

H. Kumigashira, T. Takahashi, S. Yoshii, and M. Kasaya Department of Physics, Tohoku University, Sendai 980-8578, Japan

Ultrahigh-resolution photoemission spectroscopy ($\Delta E \sim 8$ meV) has been performed on CeRhAs and CeRhSb to study the mechanism of (pseudo)gap formation in the Kondo insulators. Using the difference in the photoionization cross section between Ce 4f electrons and conduction electrons, we have successfully separated the Ce 4f from the conduction-electron partial density of states (DOS) in the spectra. We found that the both conduction-electron-derived and 4f-derived DOS show a depletion (pseudogap) at E_F in contrast to metallic Kondo materials. With increasing the temperature, these pseudogaps gradually disappear by filling with additional intensity within the pseudogap, reflecting the temperature induced metal-insulator transition in CeRhAs and CeRhSb. It was also found that the size of f-pseudogap is always smaller than that of conduction electrons (c-pseudogap) while both scale well with the Kondo temperature. These results are qualitatively consistent with the theoretical prediction from the Anderson lattice model at half-filling, indicating that the hybridization between 4f and conduction electrons near E_F is essential for the Kondo gap in the Ce-based compounds.